## (SP-05)

## Fabrication of Organic-Inorganic Hybrid Multi-layers by Using Molecular Layer Deposition in Vacuum

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We have been studied the formation of organic-inorganic hybrid self-assembled multi-layers using molecular layer deposition at the gas phase. Alkylsiloxane monolayers has been formed on TiO<sub>2</sub>/Si substrates at 200°C in the gas phase. In order to modify the terminal alkyl groups of DTS monolayers, it was activated by ultra-violet/ozone/H<sub>2</sub>O at 200°C. The TiO<sub>2</sub> thin films were grown on SAMs by atomic layer deposition from titanium isopropoxide and water. The multi-layers have been investigated by X-ray photoelectron spectroscopy (XPS), contact angle analysis (CAA) and transmission electron microscopy (TEM).